

Applicant: Lih-Ping Li  
Serial No.: 10/810,912  
Attorney Docket No.: 67,200-1256

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**IN THE SPECIFICATION**

Please amend the abstract of the disclosure as follows.

Abstract of the Disclosure

A ~~new~~ method for seasoning a process chamber to substantially reduce the quantity of particulate residues remaining in the chamber after semiconductor fabrication or other processes are carried out in the chamber, is disclosed. The seasoning method includes providing a seasoning film on the interior surfaces of a process chamber, typically after cleaning of the chamber. Accordingly, ~~the quantity of particulate by-product residues which remain in the chamber after processing is substantially reduced.~~